5 What is claimed:

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1. A method of manipulating charged particles of a beam of charged particles by a magnetic field, the method comprising:

providing a magnetic field generating apparatus having a magnetic-flux-carrying body made of a material with a high permeability number, and at least one current conductor engaging at least partially around the magnetic-flux-carrying body, and

operating the magnetic-flux-carrying body at a operating temperature,

wherein the permeability number of the material 20 temperature dependent, and the material and the operating temperature are chosen such that the operating temperature is within a temperature range, in which the following applies:

 $\frac{\mu_{max} - \mu_{min}}{\mu_{max} \cdot \Delta T} = c , \text{ with } c < 3 \cdot 10^{-3} \text{ K}^{-1}$

wherein

30 μ_{max} is a maximum value of the permeability number in the temperature range,

 μ_{min} is a minimum value of the permeability number in the temperature range, and

 ΔT is a width of the temperature range.

- 2. The method according to claim 1, wherein c is less than $9 \cdot 10^{-4} \text{ K}^{-1}$.
- 5 3. The method according to claim 1, wherein c is less than $3 \cdot 10^{-4}$ K⁻¹.
 - 4. The method according to claim 1, wherein c is less than $9 \cdot 10^{-5} \text{ K}^{-1}$.

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- 5. The method according to claim 1, wherein c is less than $3\cdot 10^{-5}~\text{K}^{-1}$.
- 6. The method according to claim 1, wherein c is less than $9 \cdot 10^{-6} \text{ K}^{-1}$.
 - 7. The method according to claim 1, wherein c is less than $3\cdot 10^{-6}~\text{K}^{-1}$.
- 20 8. The method according to claim 1, wherein c is less than $1 \cdot 10^{-6} \text{ K}^{-1}$.
- 9. The method according to claim 1, wherein a temperature dependency of the material has an extremum in the temperature range.
 - 10. The method according to claim 9, wherein the operating temperature is substantially a temperature at which the temperature dependency has the extremum.

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11. The method according to claim 1, wherein the permeability number of the material is higher than 5,000.

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12. The method according to claim 1, wherein the permeability number of the material is higher than 8,000.

- 5 13. The method according to claim 1, wherein the permeability number of the material is higher than 10,000.
- 14. A particle optical system having a particle-optical

 10 apparatus for providing a magnetic field for

 manipulating charged particles of a beam of charged

 particles, the particle-optical apparatus comprising:

a magnetic-flux-carrying body made of a material with a high permeability number,

at least one current conductor engaging at least partially around the magnetic-flux-carrying body, and

- a temperature-adjusting unit configured for adjusting a temperature of the magnetic-flux-carrying body substantially to a nominal temperature,
- wherein the permeability number of the material is temperature-dependent and the nominal temperature is within a temperature range, in which the following applies:

$$\frac{\mu_{\text{max}} - \mu_{\text{min}}}{\mu_{\text{max}} \cdot \Delta T} = c \text{, with } c < 3 \cdot 10^{-3} \text{ K}^{-1}$$

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wherein

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 μ_{max} is a maximum value of the permeability number in the temperature range,

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 μ_{min} is a minimum value of the permeability number in the temperature range, and

 ΔT is a width of the temperature range.

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15. The particle-optical system according to claim 14, wherein a temperature dependency of the material exhibits an extremum in the temperature range.

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16. The particle-optical system according to claim 15, wherein the nominal temperature is substantially a temperature at which the temperature dependency exhibits the extremum.

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17. The particle-optical system according to claim 14, wherein the temperature-adjusting unit comprises a temperature sensor for detecting the temperature of the magnetic-flux-carrying body.

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- 18. The particle-optical system according to claim 14, wherein the material is a soft-magnetic material.
- 19. The particle-optical system according to claim 14, wherein the material is a ferrite material.
 - 20. The particle-optical system according to claim 14, wherein the is lithography system a system transferring a pattern onto particle-sensitive a substrate using at least one writing beam of charged particles.
- 21. The particle-optical system according to claim 14, wherein the system is a microscopy system for inspecting an object.